

Magnetron Sputter Deposition of Nitride Thin Films and Nanostructures

Guest Editors:

Dr. Ching-Lien Hsiao

Nanomaterials Science Unit, Thin Film Physics Division, Department of Physics, Chemistry, and Biology, Linköping University, 58183 Linköping, Sweden

Dr. Arnaud le Febvrier

Energy Materials Unit, Thin Film Physics Division, Department of Physics, Chemistry, and Biology, Linköping University, 58183 Linköping, Sweden

Deadline for manuscript submissions:

closed (28 February 2022)

Message from the Guest Editors

Dear Colleagues,

We would like to invite you to submit your work to a Special Issue on “Magnetron Sputter Deposition of Nitride Thin Films and Nanostructures”. Nitride compounds are employed to enhance/strengthen the materials properties of many tools and to fabricate electronic and optoelectronic devices commonly used in our daily life.

Magnetron sputter deposition (MSD) is one of the most common techniques used for the coating of thin films and nanostructures in both academia and industry, thanks to its versatility, environmentally friendly deposition process, and suitability for very large area coatings.

This scope of this Special Issue is mainly illustrated by, but not limited to, the following concepts:

- Magnetron-sputtered nitride thin films and nanostructures
- Development of novel nanostructures by MSD
- Study of the effect of sputtering parameters on grown materials properties
- Modelling of magnetron sputtering processes for growing nitrides
- Applications of sputtered nitrides and hybrids
- Functionalization of nitride thin films and nanostructures for various applications
- Advances in process development and modeling



Editors-in-Chief

Prof. Dr. Wei Pan

State Key Laboratory of New
Ceramics and Fine Processing,
School of Materials Science &
Engineering, Tsinghua University,
Beijing 100084, China

Dr. Emerson Coy

NanoBioMedical Centre, Adam
Mickiewicz University in Poznań,
ul. Wszechnicy Piastowskiej 3, 61-
614 Poznań, Poland

Message from the Editorial Board

Now more than ever, research is called for to produce technologies and improve knowledge to solve the major challenges faced by our society. The development of new materials and devices for (without the ambition to be exhaustive) energy, health and food technology, together with the need for establishing processes that reduce the impact on critical resources and the environment, is indeed at the center of most contemporary research. Surface science and engineering play a key role in this regard. Refining surfaces and their modifications provides new materials, architectures and processes with a huge potential to aid most societal challenges. *Coatings* is a well-established, peer-reviewed, online journal that focuses on the dissemination of publications in the field of surface science and engineering. *Coatings* publishes original research articles that report cutting-edge results and review papers on the hottest topics.

Author Benefits

Open Access: free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility: indexed within Scopus, SCIE (Web of Science), Inspec, CAPlus / SciFinder, and other databases.

Journal Rank: JCR - Q2 (*Materials Science, Coatings & Films*) / CiteScore - Q2 (*Surfaces and Interfaces*)

Contact Us

Coatings Editorial Office
MDPI, St. Alban-Anlage 66
4052 Basel, Switzerland

Tel: +41 61 683 77 34
www.mdpi.com

mdpi.com/journal/coatings
coatings@mdpi.com
X@Coatings_MDPI